

| L Number | Hits | Search Text | DB | Time stamp |
|----------|------|---|---|------------------|
| - | 3648 | oxidiz\$4 with (oxygen or hydroxyl) with (wafer or spec\$4) | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/05 13:05 |
| - | 46 | oxidiz\$4 with (oxygen or hydroxyl) with (wafer or spec\$4) with vacuum | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/05 16:43 |
| - | 26 | (oxidiz\$4 with (oxygen or hydroxyl) with (wafer or spec\$4) with vacuum) same (vessel or chamber) | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/05 16:43 |
| - | 1 | (oxidiz\$4 with (oxygen or hydroxyl) with (wafer or spec\$4) with vacuum) same (vessel or chamber) same reduct\$4 | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/05 16:22 |
| - | 8 | (oxidiz\$4 with oxygen with reduct\$4 with (wafer or spec\$4 or substrate)) same (vessel or chamber) | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/05 16:17 |
| - | 3 | ((oxidiz\$4 with oxygen with reduct\$4 with (wafer or spec\$4 or substrate)) same (vessel or chamber)) and (control\$4 near3 nozzle) | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/05 16:12 |
| - | 0 | (oxidiz\$4 with (wafer or spec\$4 or substrate)) and (oxygen with reduct\$4) and (control\$4 near3 nozzle) and ((multiple near3 nozzle) with reduct\$4) | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/05 16:20 |
| - | 0 | (vacuum adj2 (chamber or vessel)) and (oxygen with reduct\$4) and (control\$4 near3 nozzle) and ((multiple near3 nozzle) with reduct\$4) | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/05 16:21 |
| - | 0 | (vacuum adj2 (chamber or vessel)) and (oxygen with reduct\$4) and (control\$4 near3 nozzle) and ((multiple near3 nozzle) with (reduct\$4 or hydrogen)) | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/05 16:36 |
| - | 2 | (oxidiz\$4 with (oxygen or hydroxyl) with (wafer or spec\$4) with vacuum) same reduct\$4 | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/05 16:24 |
| - | 36 | ((oxidiz\$4 with oxygen) with vacuum) same reduct\$4 | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/05 16:25 |
| - | 8 | (oxygen with reduct\$4) and (control\$4 near3 nozzle) and ((multiple or number or two or three) with nozzle with (reduct\$4 or hydrogen)) | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/05 16:39 |

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| | 10 | (oxygen with reduct\$4) and (control\$4 near3 (nozzle or outlet or jet)) and ((multiple or number or two or three) with nozzle with (reduct\$4 or hydrogen)) | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/05 16:40 |
| | 17 | (oxygen with reduct\$4) and (control\$4 near3 (nozzle or outlet or jet)) and ((multiple or number or two or three) with (nozzle or outlet or jet) with (reduct\$4 or hydrogen)) | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/05 17:05 |
| | 104 | oxidiz\$4 with (oxygen or hydroxyl) with (wafer or spec\$4) with reduct\$4 | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/05 16:44 |
| | 39 | (oxidiz\$4 with (oxygen or hydroxyl) with (wafer or spec\$4) with reduct\$4) and vacuum | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/05 16:50 |
| | 835 | (apparatus with oxidiz\$5) and (oxidation with reduction) | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/05 16:55 |
| | 105 | (apparatus with oxidiz\$5) and (oxidation with reduction) and ((multiple or number or two or three) with (nozzle or outlet or jet)) | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/05 16:57 |
| | 148 | (oxygen with reduct\$4) and ((multiple or number or two or three) with (nozzle or outlet or jet) with (reduct\$4 or hydrogen)) | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/06 09:54 |
| | 1101 | 438/770,771,773,694,735,738,769,787.ccls. and ((oxidation with reduction) or oxidizing) | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/06 10:09 |
| | 320 | 438/770,771,773,694,735,738,769,787.ccls. and ((oxidation with reduction) or oxidizing) and vacuum | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/06 10:10 |
| | 254 | 438/770,771,773,694,735,738,769,787.ccls. and ((oxidation with reduction) or oxidizing) and vacuum and (chamber or vessel) | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/06 10:11 |
| | 116 | 438/770,771,773,694,735,738,769,787.ccls. and ((oxidation with reduction) or oxidizing) and vacuum and (chamber or vessel) and reduct\$4 | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/06 11:01 |
| | 110 | 438/770,771,773,694,735,738,769,787.ccls. and ((oxidation near2 reductive) or oxidizing) and vacuum and (chamber or vessel) and reduct\$4 | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/06 11:02 |
| | 110 | 438/770,771,773,694,735,738,769,787.ccls. and ((oxidation near2 reductive) or oxidizing) and vacuum and (chamber or vessel) and reduct\$4 | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/06 11:02 |

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| | 6061 | 438/770,771,773,694,735,738,769,787.ccls. | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/06 11:02 |
| | 9 | (438/770,771,773,694,735,738,769,787.ccls. and ((oxidation near2 reductive) or oxidizing) and vacuum and (chamber or vessel) and reduct\$4) and ((port or discharge or nozzle or input or ingress or entrance or entry or (spray adj heads)) with (multiple or number or two or three)) | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/10/06 11:13 |